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Complete if Known **Application Number** 10/644,817 Filing Date 8/21/2003 **First Named Inventor** R. Chellappa, et al. Art Unit 3643 **Examiner Name** Attorney Docket Number

INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary) Sheet MR2833-30 1 of

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.1		
SA	SA A1 Srinivasan S.; "Extracting Structure from Optical Flow Using the Fast Error Search Technique"; International Journal of Computer Vision; 37(3), 203–230, 2000; pp. 203 – 230		

Examiner	/Shawn An/	Date	12/06/2006
Signature	<u></u>	Considered	

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